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Insights

Krieg DeVault Helps Bring Italian-based Plastics and Resin Supplier to Anderson, Indiana

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Krieg DeVault is pleased to announce that the law firm has played a key role in completing recent negotiations for one of the first RACER Trust property redevelopments in the State of Indiana. Krieg DeVault helped Italian-based client Sirmax negotiate an incentives package enabling the plastic compounds and resins supplier to open its first North American facility located in Anderson, Indiana.

Sirmax anticipates the 141,000 square foot facility built on the former General Motors location to be operational by October 2015 serving its automotive and appliance customers. The facility is projected to bring over $25 million in investment and 50 jobs to Anderson.

The Krieg DeVault team of Robert S. Schein, Sarah E. Jones, and Kevin G. Buchheit were integral in negotiating the incentives package, as well as the real estate, environmental, and construction logistics, enabling Sirmax to land in Anderson.

Regarding the importance of Sirmax's future service to Anderson, Mayor Kevin S. Smith stated, "We welcome Sirmax to Anderson. Sirmax is an important Italian company with factories in Brazil, Poland, Italy and now USA. Sirmax's announcement marks Anderson's continued record job growth, our success rebuilding the former Guide Lamp site, and our growing world-wide reputation for being a great place for new business."

Click here for additional information regarding Krieg DeVault's Economic Development and Tax Incentives services.

About Krieg DeVault LLP
Krieg DeVault LLP is a 140-professional, diversified law firm representing a wide variety of local, regional and national clients. It is a business-focused law firm with offices in Indianapolis, Carmel, Mishawaka, and Merrillville, Indiana; Chicago, Illinois; Atlanta, Georgia; Minneapolis, Minnesota; and Boca Grande and Naples, Florida. The firm's attorneys have significant experience in key areas that address the needs of a diversified client base.